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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IPA-006

Applicant : Akira Nakashima et al.
Title : METHOD OF FORMING AMORPHOUS SILICA-BASED COATING FILM
WITH LOW DIELECTRIC CONSTANT AND THUS OBTAINED
SILICA-BASED COATING FILM
Serial No. : 10/533,238
Filed : June 16, 2005
Group Art Unit : 2891
Examiner :

Hon. Commissioner of Patents
P.O. Box 1450, Alexandria, VA 22313-1450

January 19, 2007

SUBMISSION OF INFORMATION DISCLOSURE STATEMENT

Sir:

Submitted herewith are Information Disclosure Statement, European Search Report and five references.

Attached herewith is a credit card authorization form to cover the Surcharge for filing an IDS in the amount of \$180.00.

Respectfully submitted,
KANESAKA BERNER & PARTNERS

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<p style="text-align: center;">INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)</p> <p style="text-align: center;">U.S. PATENT DOCUMENTS</p>			ATTY. DOCKET NO. IPA-006		U.S. PATENT APPLICATION NO. 10/533,238							
			APPLICANT Akira Nakashima et al.									
			FILING DATE 06/16/2005		GROUP 2891							
FOREIGN PATENT DOCUMENTS												
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation						
						<input checked="" type="checkbox"/> Yes	<input type="checkbox"/> No					
						EP 0 226 208 A2	12/16/1986	Europe			<input checked="" type="checkbox"/> X	
						EP 1 146 092 A2	04/09/2001	Europe			<input checked="" type="checkbox"/> X	
						EP 1 142 832 A1	04/04/2001	Europe			<input checked="" type="checkbox"/> X	
						EP 1 197 999 A1	12/15/2000	Europe			<input checked="" type="checkbox"/> X	
JP 2002-030249	01/31/2002	Japan			<input checked="" type="checkbox"/> X							
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)												
EXAMINER			DATE CONSIDERED									

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.